

## EAST Search History

## EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S2	13	("20020056838"   "20020056838"   "20040005739"   "20040005739"   "20050026423"   "20050026423"   "20050037614"   "20050037614"   "5747930"   "6614053"   "6614053"   "6767772"   "6767772").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 18:46
S3	3864	(display and (drain with gate with connect\$3)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 18:48
S4	559	S3 and ((electron and hole) near2 (inject\$3 transport \$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 18:49
S5	374	S3 and ((electron with hole) near2 (inject\$3 with transport\$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 18:50
S7	111	(organic near2 (el electro electrolumescen\$2)).clm. and (nitrogen with (insulation insulating planarization defining spacer))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 19:32
S9	2	(organic near2 (el electro electrolumescen\$2)).clm. and ((protect\$3) with (scan and signal) with line)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 19:41
S10	10	(organic near2 (el electro electrolumescen\$2)).clm. and ((protect\$3 adj circuit) with (scan signal))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 19:42

S11	866	(organic near2 (el electro electroluminescen\$2)).clm. and ((droplet ink) near2 method)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 19:48
S12	165	(organic near2 (el electro electroluminescen\$2)).clm. and ((droplet ink) near2 method) and (mask\$3 same etch\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 19:48
S14	88	(organic near2 (el electro electroluminescen\$2)).clm. and (droplet near2 discharge)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 19:53
S16	6	(organic near2 (el electro electroluminescen\$2)).clm. and (treat\$3 with photocatalyst)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 19:58
S17	165	(organic near2 (el electro electroluminescen\$2)).clm. and ((remov\$3 clean\$3) with (organic) with water)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 20:19
S19	0	(organic near2 (el electro electroluminescen\$2)).clm. and (planariz\$3 with spray \$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 20:38
S20	16	(planariz\$3 with spray\$3 with gas)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 20:38
S21	2	"5747930".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 20:47
S22	2020	((droplet (ink near2 jet) inkjet) near3 method) and planariz\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 20:54
S23	394	((droplet (ink near2 jet) inkjet) near3 (method process)) and (planariz\$3 with process)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 20:55

S24	70	S23 and @pd<"20031114"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/04/12 20:55
S25	1	10/576495	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:24
S26	8025	(organic near2 (el electro electroluminescen\$2)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:26
S27	8517	313/504,506.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:28
S28	13018	S26 S27	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:28
S29	40	S28 and ((photocatalyst (photo near2 catalyst)) with substrate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:29
S31	26	S28 and ((photocatalyst (photo near2 catalyst)) with (treat treatment pretreat pretreatment))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:31
S33	13300	313/498-512.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:34
S34	17462	S26 S33	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:34
S35	27	S34 and ((photocatalyst (photo near2 catalyst)) with (treat treatment pretreat pretreatment))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:34

S37	171	((photocatalyst (photo near2 catalyst)) with (treat treatment pretreat pretreatment) with substrate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:35
S39	2	((photocatalyst (photo near2 catalyst)) with (treat treatment pretreat pretreatment) with substrate with ((ink near2 jet) droplet))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:37
S40	180	((photocatalyst (photo near2 catalyst)) with substrate with (transistor tft gate electrode))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:51
S41	26	S34 and S40	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:52
S43	14	((photocatalyst (photo near2 catalyst)) with substrate with (pretreat pretreatment treat treatment) with (adhesivity adhesion))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/29 23:56
S44	182	((photocatalyst (photo near2 catalyst)) with substrate with (adhesivity adhesion))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/30 00:12
S45	168	S44 not S43	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/30 00:12
S47	410	(gate near2 electrode) with (convex concave curved semicircular) with shape	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/30 00:53
S48	8	S34 and S47	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/30 00:53

S51	220994	(electrode with (liquid ink droplet))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/30 01:10
S52	216882	(electrode with (liquid ink))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/30 01:10
S53	2008	S34 and S52	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/10/30 01:11

**EAST Search History (Interference)**

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**4/28/2010 10:54:31 AM**

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